## **Supporting Information**

## **Thiophene-Modified Doubleshell Hollow g-C<sub>3</sub>N<sub>4</sub> Nanosphere Boosts**

## NADH Regeneration via Synergistic Enhancement of Charge

## **Excitation and Separation**

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Material	Specific surface area (m <sup>2</sup> g <sup>-1</sup> )	Pore size distribution (nm)
Bulk C <sub>3</sub> N <sub>4</sub>	10.3	3.9
ATCN-DSCN-0	71.5	3.9
ATCN-DSCN-0.001	74.3	3.9
ATCN-DSCN-0.005	103.69	3.9
ATCN-DSCN-0.010	60.9	3.9

Table S1. The calculated BET specific surface areas of different  $C_3N_4$  materials

C 1s						
	N-C=N			C-C		
	Position	Area	Area percentage(%)	Position	Area	Area percentage(%)
undoped	288.0	13625.6	87.69	284.6	1912. 6	12.31
doped	287.9	24236.9	77.80	284.6	6917. 6	22.20

**Table S2.** Relative ratios of N-C=N and C=C of ATCN-DSCN-0 (undoped) and ATCN-DSCN-0.005(doped) by C 1s spectral analysis.

			undoped	doped
	C-N=C	Position	398.4	398.4
		Area	22614.6	41053.4
		Area percentage(%)	66.49	67.77
	N-(C) <sub>3</sub>	Position	399.7	399.7
		Area	7667.9	12911.4
N 1s		Area percentage(%)	22.55	21.31
	C-N=C	Position	401.0	400.9
		Area	2116.4	3869.2
		Area percentage(%)	6.22	6.39
	$\pi$ bonding	Position	404.5	404.4
		Area	1611.3	2746.7
		Area percentage(%)	4.74	4.53

**Table S3.** Relative ratios of C-N=C, N-(C)<sub>3</sub> and C-N=C of ATCN-DSCN-0 (undoped) and ATCN-DSCN-0.005 (doped) by N 1s spectral analysis.

S 2p						
	S 2p <sub>3/2</sub>			S 2p <sub>1/2</sub>		
	Position	Area	Area percentage(%)	Position	Area	Area percentage(%)
undope d	_	_	_	_	_	-
doped	163.9	381.3	66.67	164.9	190.6	33.33

**Table S4.** Relative ratios of S  $2p_{3/2}$  and S  $2p_{1/2}$  of ATCN-DSCN-0 (undoped) and ATCN-DSCN-0.005 (doped) by S 2p spectral analysis.



**Figure S1.** SEM and TEM images of SiO<sub>2</sub> (template), ATCN-DSCN-0 (undoped), ATCN-DSCN-0.001 (the weight ratio of ATCN: SiO<sub>2</sub> is 0.001) and ATCN-DSCN-0.010 (the weight ratio of ATCN: SiO<sub>2</sub> is 0.010). (a) SEM image of SiO<sub>2</sub>, which can be seen the slippy surface of SiO<sub>2</sub>. (b) TEM image of SiO<sub>2</sub>, which can be seen the hollow doubleshell structure of SiO<sub>2</sub>. (c) SEM image of ATCN-DSCN-0, which can be seen the uniformity and the rough surface of ATCN-DSCN-0. (d) TEM image of ATCN-DSCN-0, which can be seen the diameter and shell thickness of ATCN-DSCN-0. (e) SEM image of ATCN-DSCN-0.001, which can be seen the uniformity and the rough surface of ATCN-DSCN-0. (f) TEM image of ATCN-DSCN-0.001, which can be seen the diameter and shell thickness of ATCN-DSCN-0.001. (g) SEM image of ATCN-DSCN-0.010, which can be seen the uniformity and the rough surface of ATCN-DSCN-0.010. (h) TEM image of ATCN-DSCN-0.010, which can be seen the diameter and shell thickness of ATCN-DSCN-0.010. (h)



**Figure S2.** N<sub>2</sub> adsorption-desorption isotherm and Barret-Joyner-Halenda (BJH) pore size distribution plot (inset) of (a) hollow doubleshell SiO<sub>2</sub> and (b) hollow ATCN-DSCN-0, ATCN-DSCN-0.001 and ATCN-DSCN-0.010.



**Figure S3.** The surface elements analysis of ATCN-DSCN-0 (undoped DSCN). (a) Full scan X-ray photoelectron spectroscopy (XPS) spectra of ATCN-DSCN-0 (undoped). (b) High-resolution C 1s spectra of ATCN-DSCN-0. (c) High-resolution N 1s spectra of ATCN-DSCN-0. (d) High-resolution S 2p spectrum of thiophene undoped DSCN (ATCN-DSCN-0).



**Figure S4.** Photo-regenerated NADH yield. The yield of the photo-regenerated NADH with different levels of  $[Cp*Rh(bpy)H_2O]^{2+}$  (pH=7, and ATCN-DSCN-0.005 was used).



Figure S5. The UV-vis diffuse reflectance spectra (UV-Vis DRS) of thiophene (ATCN).



Figure S6. The photoluminescence spectra (PL) of thiophene (ATCN) with an excitation wavelength of 350 nm.



**Figure S7.** The NMR spectrum of the organometallic compound [Cp\*Rh(bpy)Cl]Cl. <sup>1</sup>H NMR (300 MHz, CDCl3): Cp\*[Rh(2,2'-bpy)] δ (ppm) = 9.08 (d, 2H, H-3,3'), 8.86 (d, 2H, H-6,6'), 8.26 (t, 2H, H-5,5'), 7.84 (t, 2H, H-4,4'), 1.75 (s, 15H, Cp\*).



**Figure S8.** The mass spectra of compound [Cp\*Rh(bpy)Cl]Cl dissolved in methanol, which indicates that the gross mass of [Cp\*Rh(bpy)Cl]Cl is approximately 465.9196.